

Freeform Search

Database: <input type="checkbox"/> US Pre-Grant Publication Full-Text Database <input type="checkbox"/> US Patents Full-Text Database <input type="checkbox"/> US OCR Full-Text Database <input type="checkbox"/> EPO Abstracts Database <input type="checkbox"/> JPO Abstracts Database <input type="checkbox"/> Derwent World Patents Index <input type="checkbox"/> IBM Technical Disclosure Bulletins	Term: <input type="text" value="5532094.pn."/>
Display: <input type="text" value="10"/> Documents in Display Format: <input type="text" value="-"/> Starting with Number <input type="text" value="1"/>	
Generate: <input type="radio"/> Hit List <input checked="" type="radio"/> Hit Count <input type="radio"/> Side by Side <input type="radio"/> Image	

Search **Clear** **Interrupt**

Search History

DATE: Thursday, February 05, 2004 [Printable Copy](#) [Create Case](#)

<u>Set</u>	<u>Hit</u>	<u>Set</u>
<u>Name</u>	<u>Count</u>	<u>Name</u>
<u>side by</u>		<u>result</u>
<u>side</u>		<u>set</u>
<i>DB=PGPB,USPT; PLUR=YES; OP=ADJ</i>		
<u>L24</u> L22 and polish	0	<u>L24</u>
<u>L23</u> L22 and polishing	0	<u>L23</u>
<u>L22</u> 5532094.pn.	1	<u>L22</u>
<u>L21</u> 5232094.pn.	1	<u>L21</u>
<u>L20</u> l12 and (solution or slurry) near10(halogen or polyhalide)	63	<u>L20</u>
<u>L19</u> l12 and (halogen or polyhalide) near3 ion	84	<u>L19</u>
<u>L18</u> L17	0	<u>L18</u>
<u>L17</u> l12 and (halogen or polyhalide) near3 ion	0	<u>L17</u>
<u>L16</u> l12 and (halogen or polyhalide)	1294	<u>L16</u>
<i>DB=USPT,PGPB,JPAB,EPAB,DWPI,TDBD; PLUR=YES; OP=ADJ</i>		
<u>L15</u> L14 not L13	111	<u>L15</u>
<u>L14</u> L12 and L10	123	<u>L14</u>
<u>L13</u> L12 and L11	12	<u>L13</u>
<u>L12</u> (51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS.	25226	<u>L12</u>

<u>L11</u>	L10 and edta (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)	166	<u>L11</u>
<u>L10</u>	and ((polymer near2 particle or abrasive) same (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon))	2231	<u>L10</u>
<u>L9</u>	L6 and (surfactant or passivating or triazole or benzotriazole or chelating or edta or ethylenediaminetretacetic or polymer)	24	<u>L9</u>
<u>L8</u>	polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)) and (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon)	67	<u>L8</u>
<i>DB=USPT,PGPB; PLUR=YES; OP=ADJ</i>			
<u>L7</u>	polishing near20 (solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)) and (polystyrene or polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon)	59	<u>L7</u>
<u>L6</u>	L5 not L4 (51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and polishing near20	46	<u>L6</u>
<u>L5</u>	(solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)) (51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and polishing near20	55	<u>L5</u>
<u>L4</u>	(solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)).clm.	9	<u>L4</u>
<u>L3</u>	L2 and (polytetrafluoroethylene or polyamide or silver or porous silica or porous silicon) near10 (particle or abrasive)	29	<u>L3</u>
<u>L2</u>	(51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)	1397	<u>L2</u>
<u>L1</u>	(51/307 51/308 51/309 OR 106/3 OR 252/79.1 252/79.2 252/79.3 252/79.4 252/79.5 OR 438/692 438/693 OR 216/\$)!CCLS. and solution near5 (iodine or bromine or fluorine or sulfuric or hydrochloric or carbonic or iodide)	1330	<u>L1</u>

END OF SEARCH HISTORY